## BEST AVAILABLE COPY





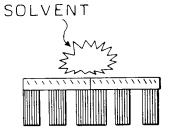
FIG. 2A

F1G.2B



WAFER AFTER RESIST RECESS AND ETCHING

PUT INTO TRACK APPLY SOLVENT



SPINNING

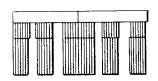
FIG.2C





SPINNING





PUT INTO BALANCE AND WEIGHT OBTAIN WEIGHT W2

PUT INTO BALANCE AND WEIGHT OBTAIN WEIGHT WI

BAKE, REMOVE SOLVENT

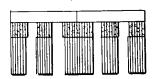


FIG.2E